



SLOVENSKI STANDARD
oSIST prEN ISO 22765:2024
01-februar-2024

Tehnologija jedrskih goriv - Sintrani peleti (U, Pu)O₂ - Navodilo za pripravo keramografske preiskave mikrostrukture (ISO/DIS 22765:2023)

Nuclear fuel technology - Sintered (U,Pu)O₂ pellets - Guidance for ceramographic preparation for microstructure examination (ISO/DIS 22765:2023)

Kernbrennstofftechnologie - Gesinterte (U,Pu)O₂-Pellets - Leitfaden für die keramographische Herstellung der Proben zur Untersuchung des Feingefüges (ISO/DIS 22765:2023)

Technologie du combustible nucléaire - Pastilles (U,Pu)O₂ frittées - Préconisations relatives à la préparation céramographique pour examen de la microstructure (ISO/DIS 22765:2023)

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Ta slovenski standard je istoveten z: prEN ISO 22765

ICS:

27.120.30	Cepljivi materiali in jedrska gorivna tehnologija	Fissile materials and nuclear fuel technology
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en,fr,de

DRAFT INTERNATIONAL STANDARD

ISO/DIS 22765

ISO/TC 85/SC 5

Secretariat: BSI

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Nuclear fuel technology — Sintered (U,Pu)O₂ pellets — Guidance for ceramographic preparation for microstructure examination

*Technologie du combustible nucléaire — Pastilles (U,Pu)O₂ frittées — Préconisations relatives à la
préparation céramographique pour examen de la microstructure*

ICS: 27.120.30

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ISO/DIS 22765:2023(E)

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This second edition cancels and replaces the first edition (ISO 22765 :2016), which has been technically revised.

The main changes are as follows:

— refer to [Clause 1](#), [4](#), [6](#), [7](#) and [8](#)

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